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(12) **United States Design Patent**
von Hollen et al.

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(54) **FACE MASK**

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(**) Term: **14 Years**

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(30) **Foreign Application Priority Data**

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(51) **LOC (9) Cl.** **29-02**

(52) **U.S. Cl.** **D24/110.4; D24/110.1; D24/110.5**

(58) **Field of Classification Search** D24/110.1, D24/110.4, 110.5, 107, 108, 110; 128/201.21, 128/201.23-201.26

See application file for complete search history.

(56) **References Cited**

U.S. PATENT DOCUMENTS

D321,419	S	*	11/1991	Wallace	D24/110.4
D434,141	S	*	11/2000	Randeberg et al.	D24/110.4
D499,803	S	*	12/2004	Chang	D24/110.4
D582,031	S	*	12/2008	Sorensen et al.	D24/110.4
D598,537	S	*	8/2009	Nashed	D24/110.1
D615,643	S	*	5/2010	Nashed	D24/110.1
D625,405	S	*	10/2010	Nashed	D24/110.1
D658,284	S	*	4/2012	Nashed	D24/110.1
2003/0172932	A1	*	9/2003	Matioc	128/206.24

* cited by examiner

Primary Examiner — Ian Simmons

Assistant Examiner — Eleni H. Aldridge

(57) **CLAIM**

The ornamental design for a face mask, as shown.

DESCRIPTION

FIG. 1 is a perspective view showing my design;

FIG. 2 is a front elevational view thereof;

FIG. 3 is a rear elevational view thereof;

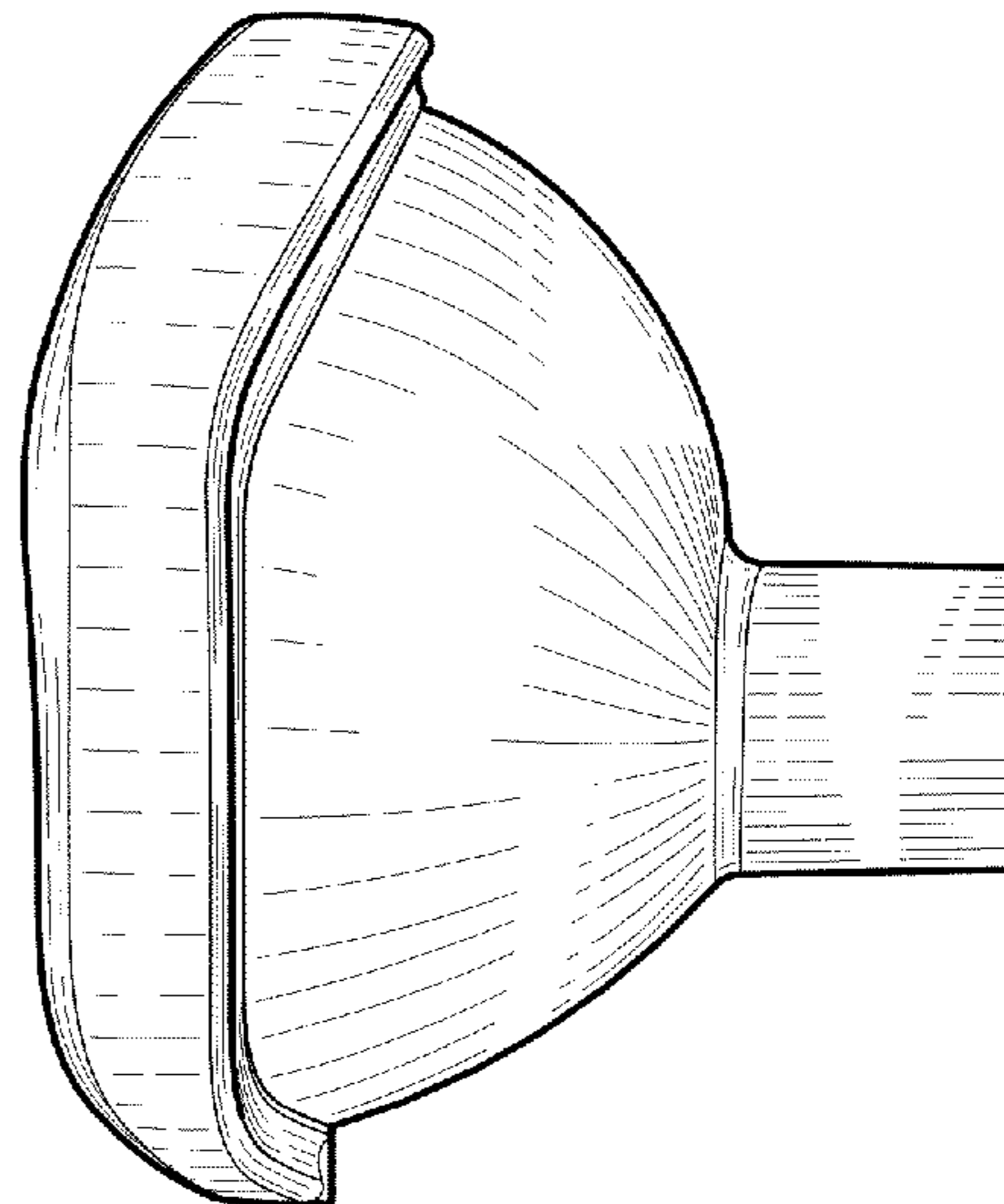
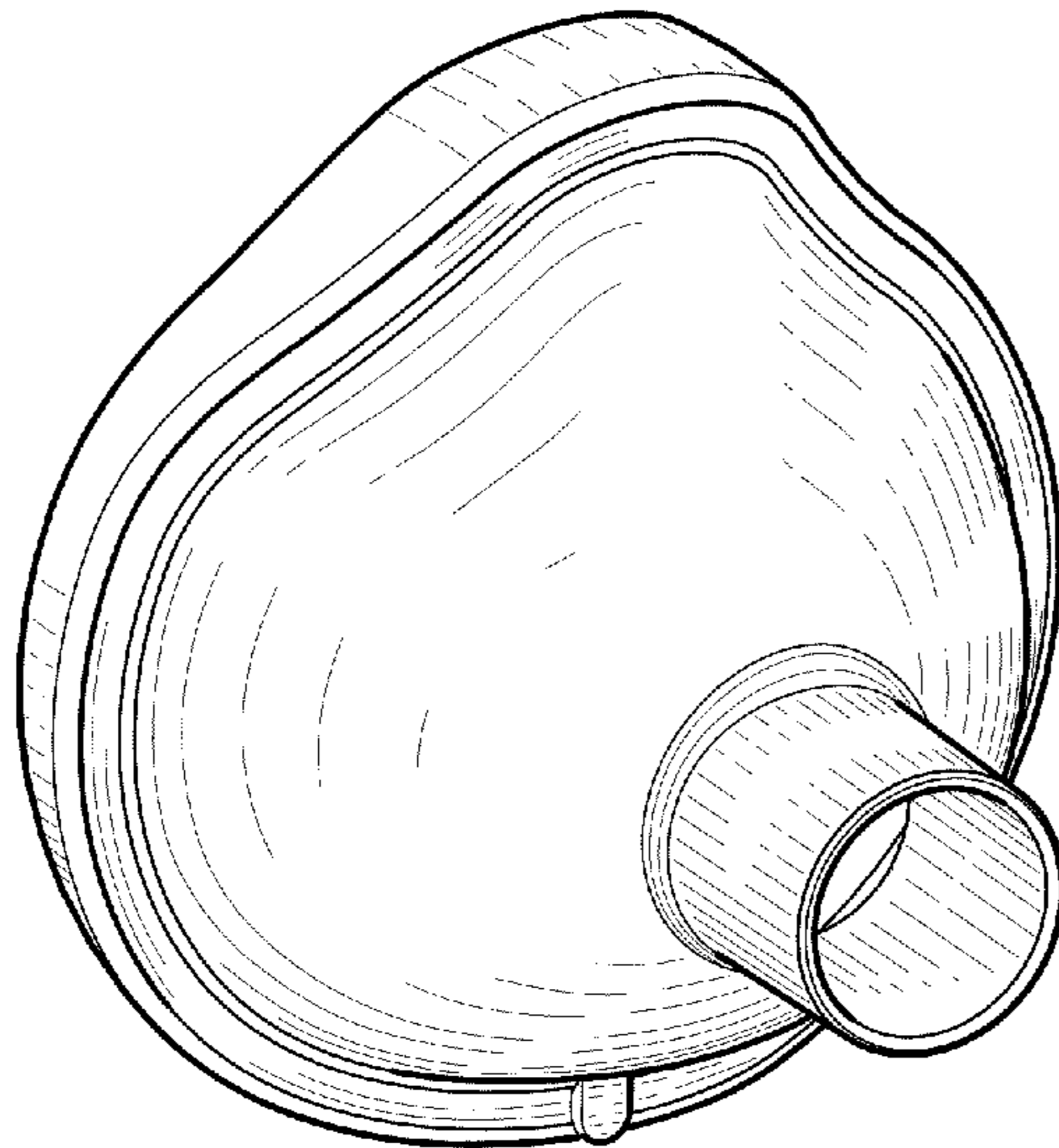
FIG. 4 is a right side elevational view thereof;

FIG. 5 is a left side elevational view thereof;

FIG. 6 is a top plan view thereof; and,

FIG. 7 is a bottom plan view thereof.

1 Claim, 4 Drawing Sheets



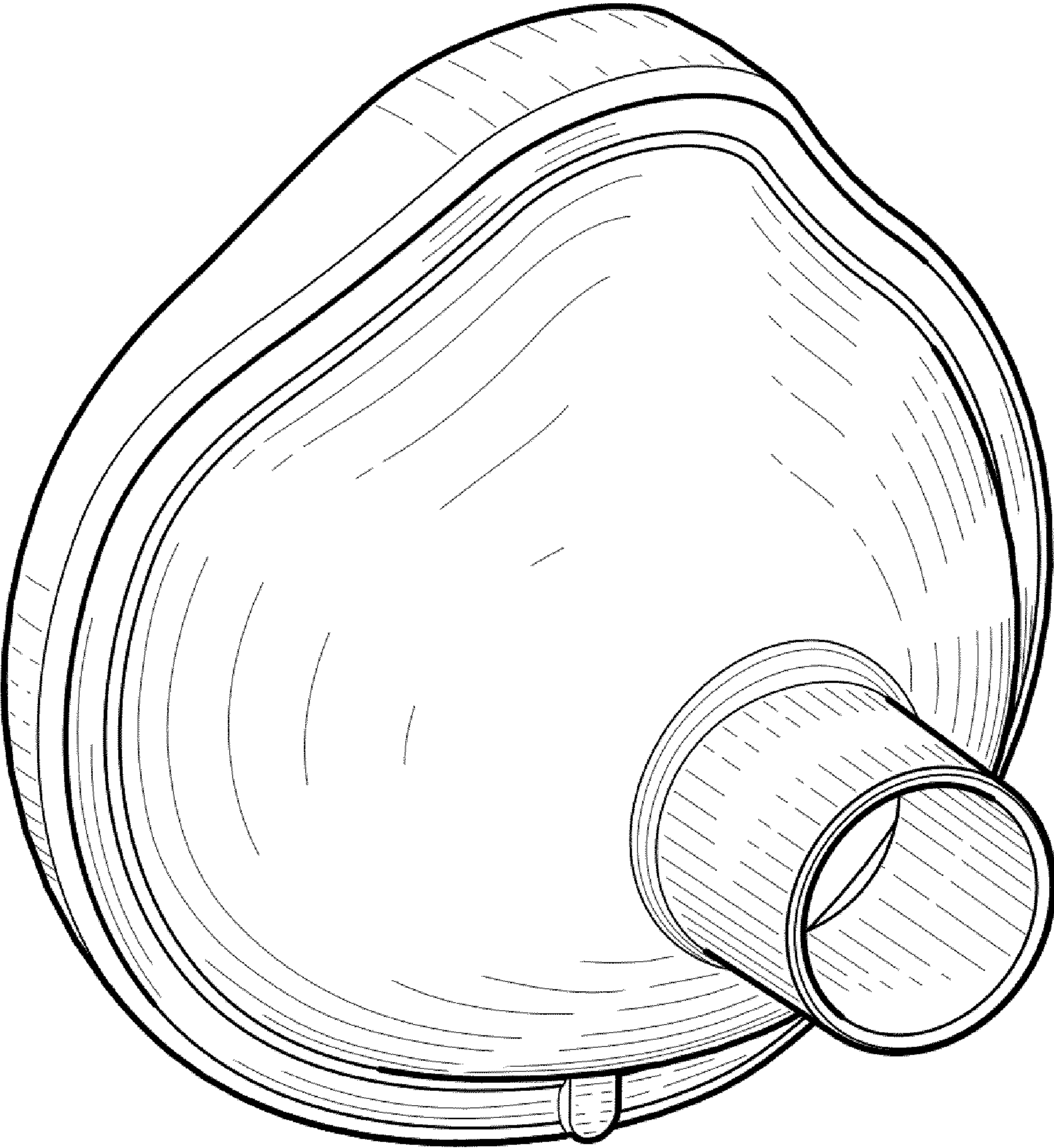


FIG. 1

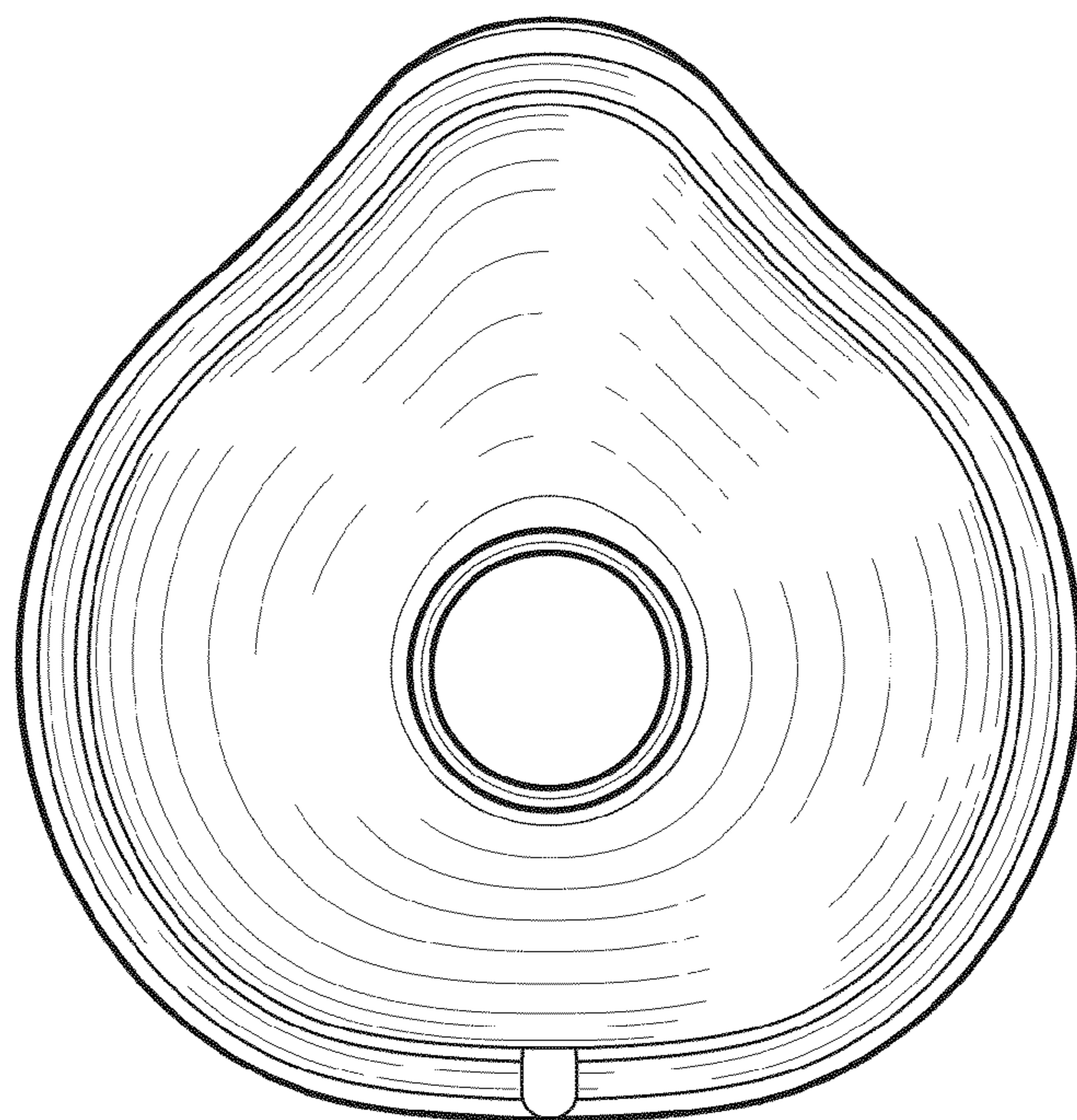


FIG. 2

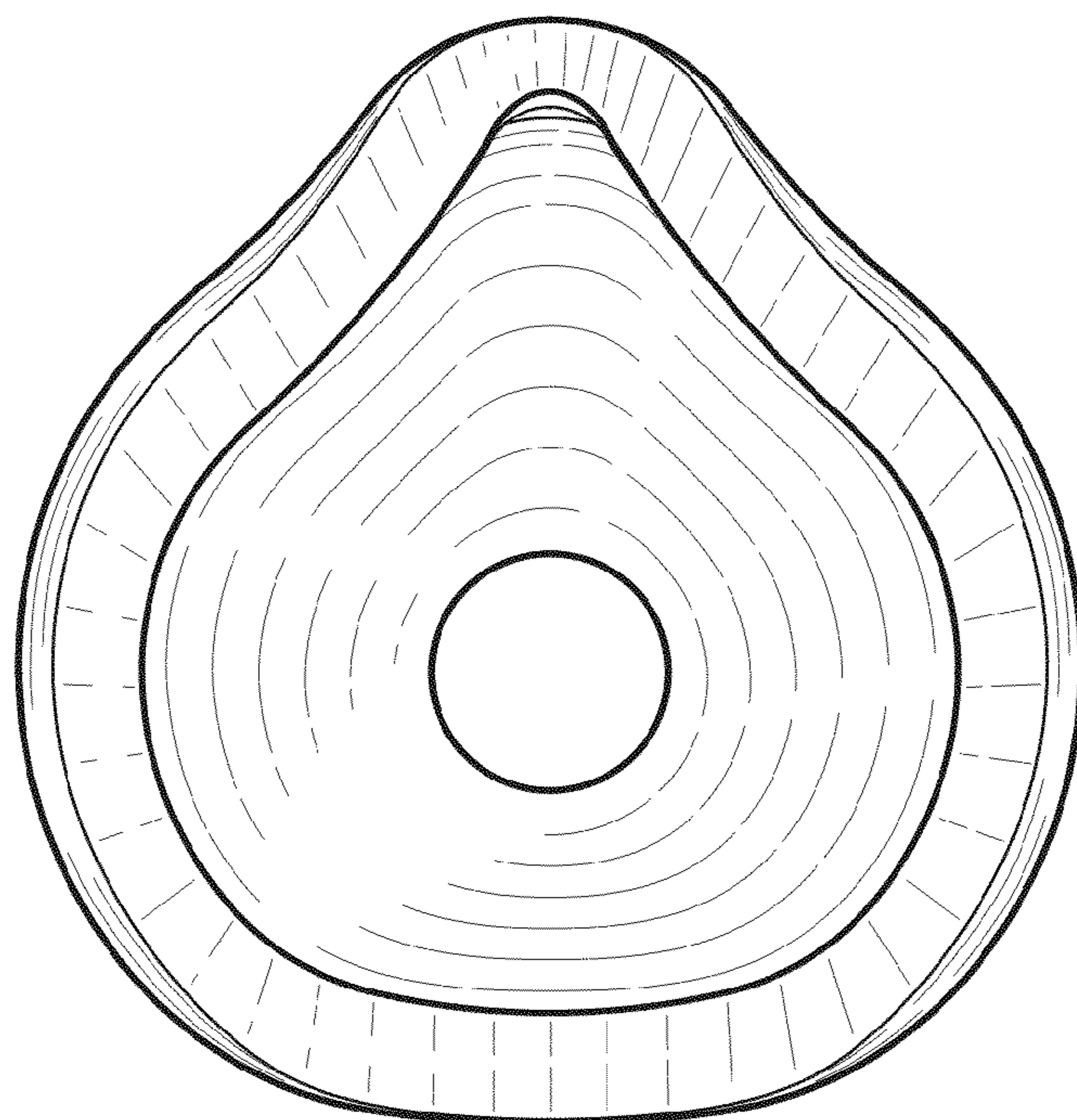


FIG. 3

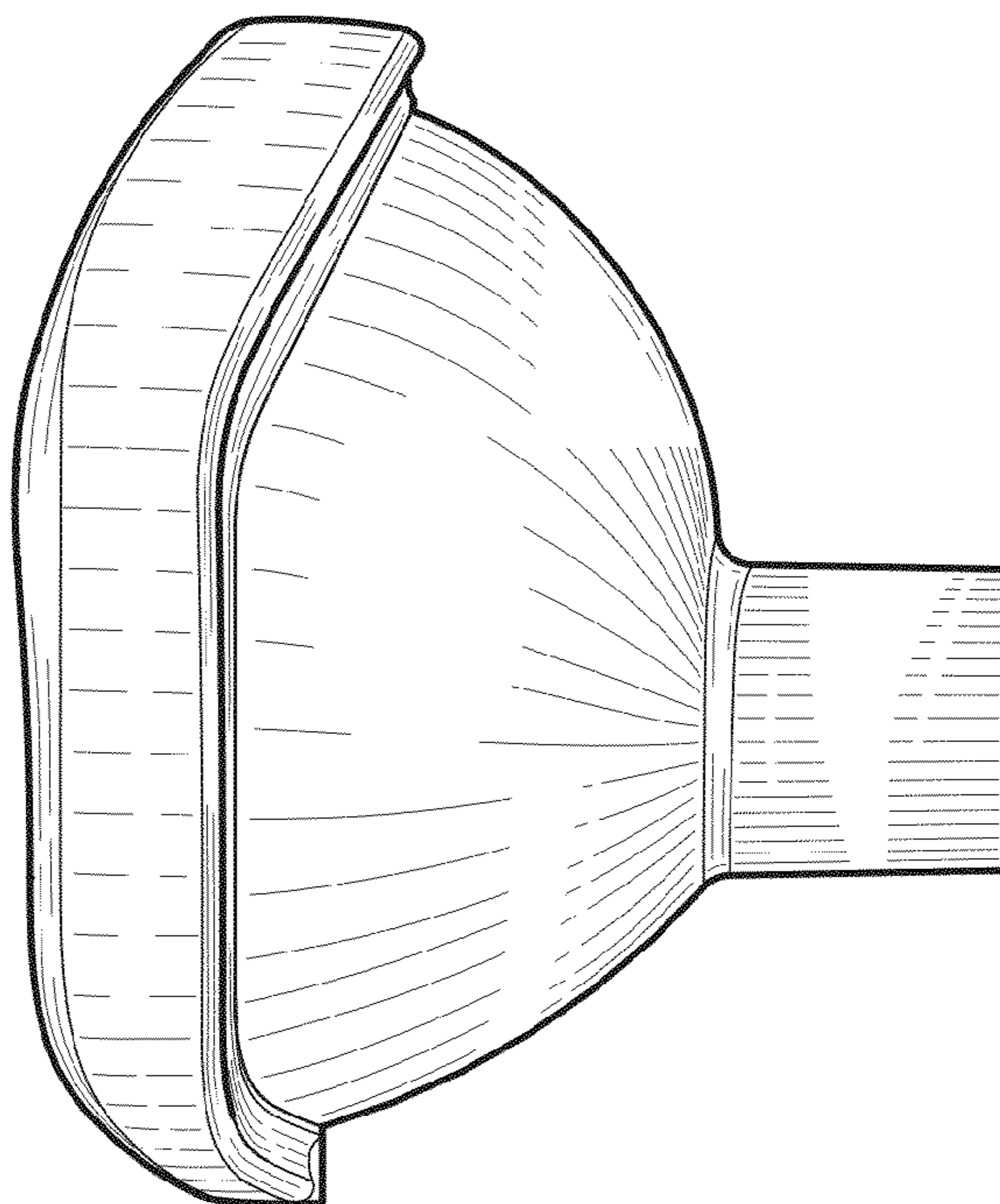


FIG. 4

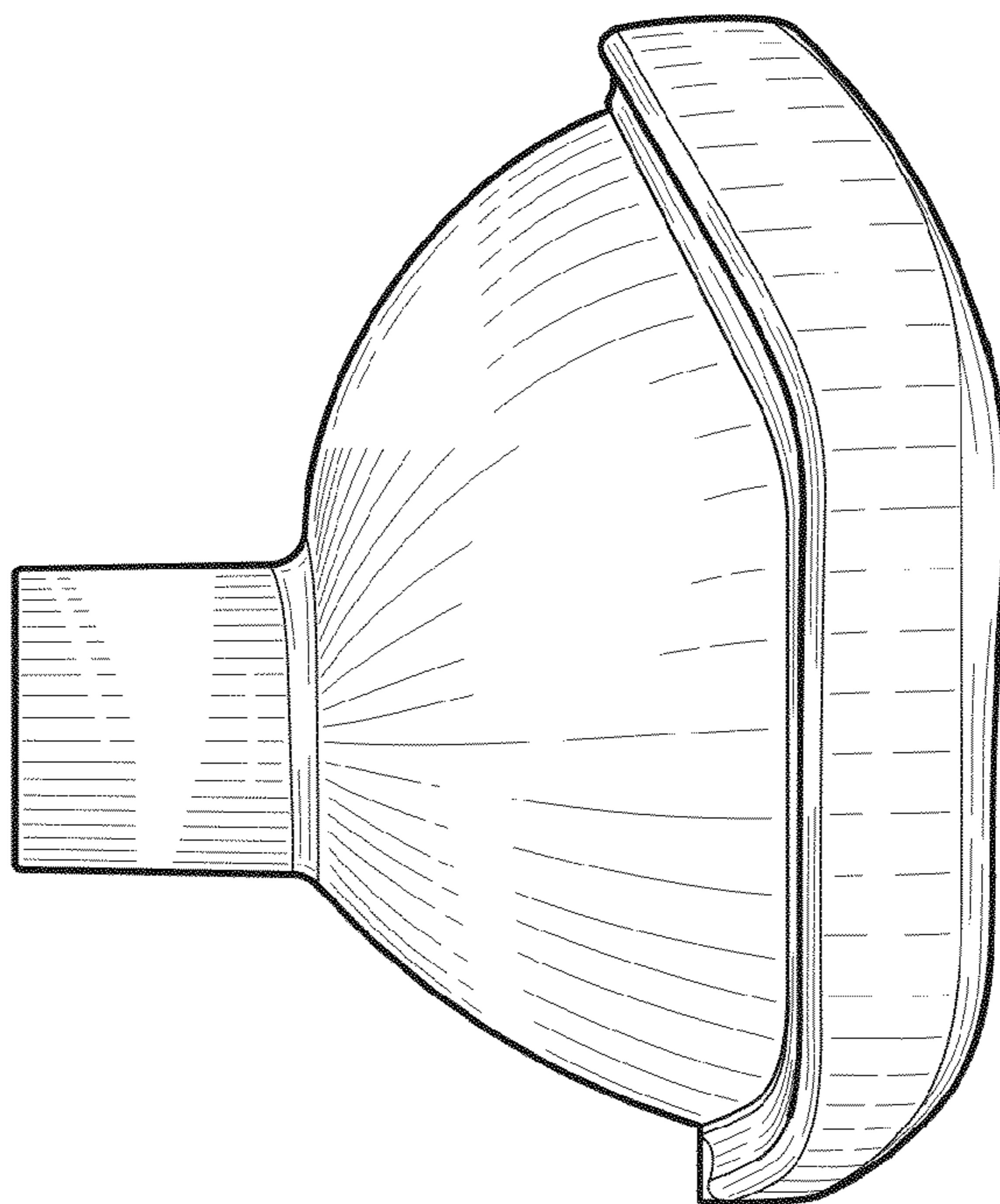


FIG. 5

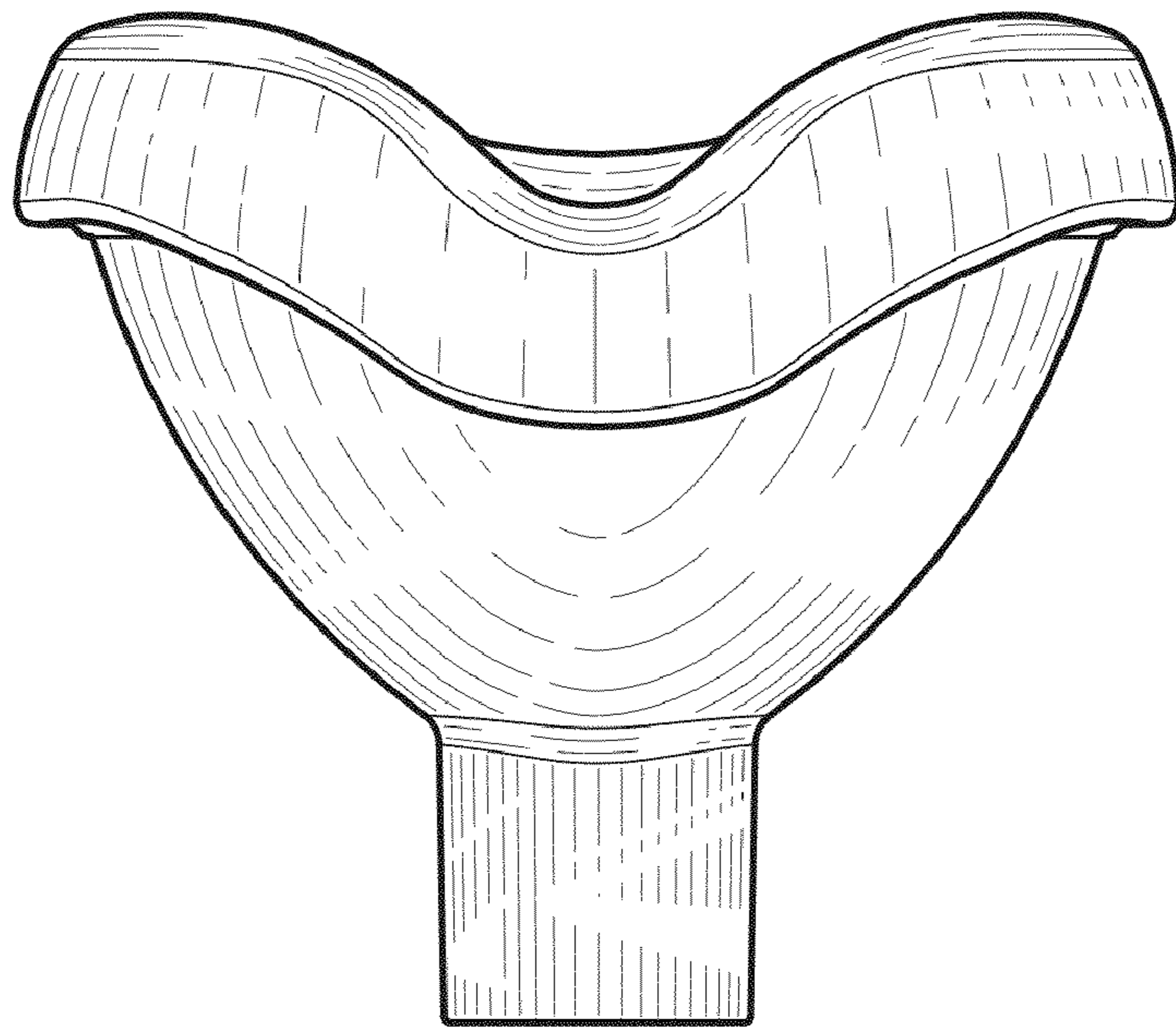


FIG. 6

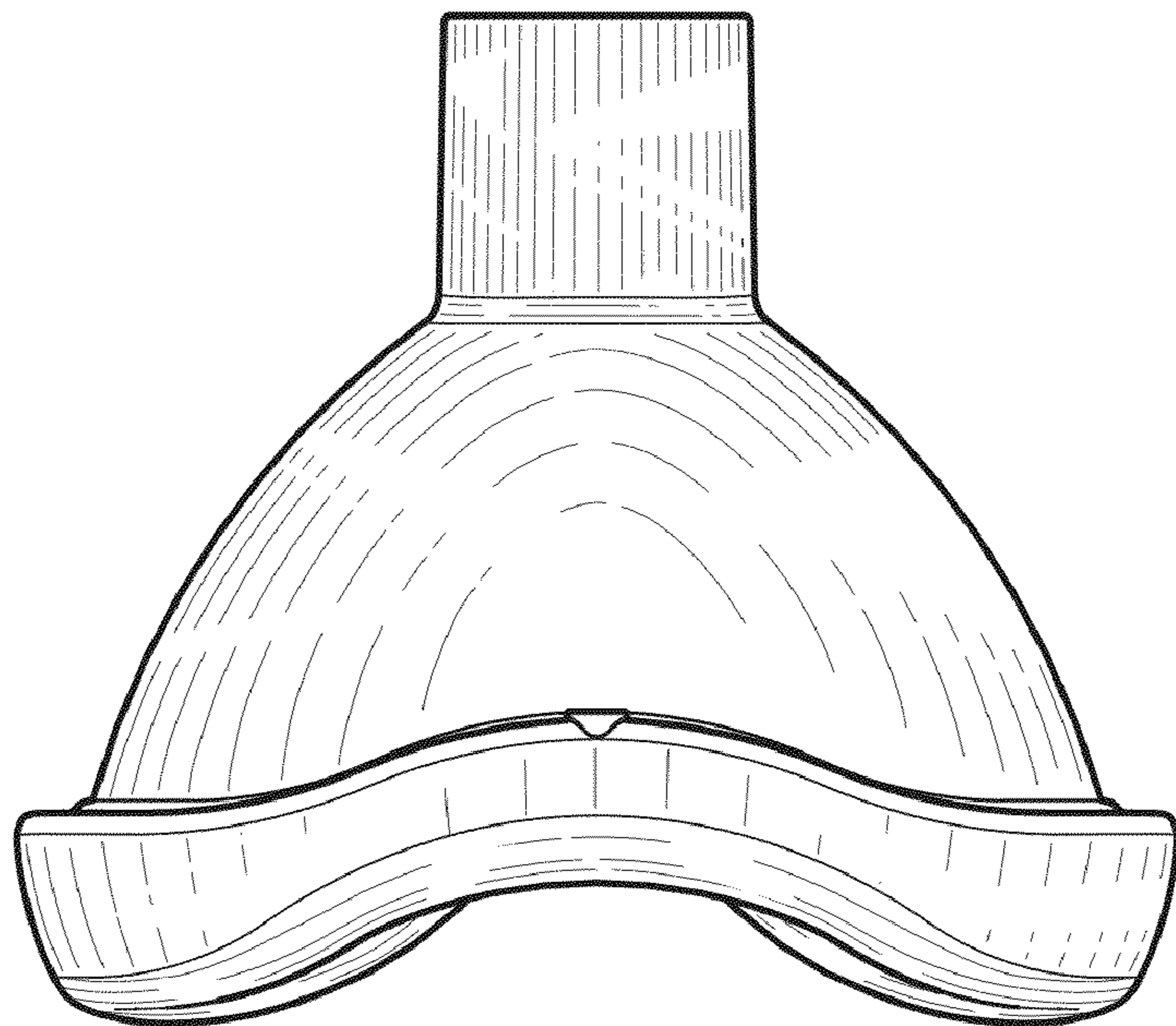


FIG. 7